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Chalcophosphate metasurfaces with multipolar resonances and electro-optic tuning†

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We computationally analyze the electro-optic response of metasurfaces consisting of interconnected nanoantennas with multipolar resonances using a chalcophosphate, Sn₂P₂S₆, as the active material. Sn₂P₂S₆ has large electro-optic coefficients and relatively low Curie temperature (<70 °C), allowing for strong changes in the refractive index of the material under moderate electric fields if the temperature can be finely controlled in proximity of the Curie point. Through numerical simulations, we show that metasurfaces designed with this nanostructured material demonstrate a significant shift of multipolar resonances upon biasing, despite moderate refractive-index values of the chalcophosphate and reduced mode localization due to this. The magnetic octupolar resonance of a dense array provides the strongest shift of spectral features upon changes in the refractive index, and we attribute it to the high mode localization of this higher-order multipole. We numerically demonstrate that narrow lattice resonances of collective nature do not provide an advantage in shifting the spectral features because of the nonlocal and delocalized nature of the modes, which are spread in the nanoantenna surrounding rather than confined inside nanoantennas. Both in-plane and out-of-plane biasing of the chalcophosphate crystals are similarly efficient with suitable electrode design, choice of electrode material, and crystal orientation within the nanoantennas. These designs exhibit optical properties similar to those of metasurfaces with isolated nanoantennas in the dense array.

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1 Introduction

Nanostructures, including metasurfaces and photonic crystals, are engineered structures with rationally designed building blocks that enable devices with distinct responses to light, acoustic waves, and heat \(\subseteq \text{ows that are not attainable with } \) naturally available materials. Optical nanostructures, with their reduced dimensions, enable the downsizing of traditional refractive optics to \square at structures. These nanostructures possess remarkable capabilities in manipulating light, showing an unusually high optical density of states, and enhancing the light-matter interaction. ¹⁻⁴ For example, the magnetic response of an antenna is essential for efficiently controlling the light it scatters. This has been the subject of active research for a long time because of the virtual absence of magnetic materials in the visible and infrared spectra, and the approximation m(u) (where m(u) is the relative magnetic permeability) remains valid in the optical range. This planar photonic technology is anticipated to enable novel physics and devices with functionalities

that differ signi□cantly from those observed in threedimensional bulk counterparts.

The Pockels effect, or linear electro-optic (EO) effect, is a nonlinear optical phenomenon observed in noncentrosymmetric materials, where an applied electric □eld modi□es the refractive index of the material. This change can be exploited to control the amplitude and polarization of light that passes through the material, which is crucial in various optical devices such as modulators and switches.⁵

An impressive number of EO nanophotonic applications have already been realized using conventional EO materials at the nanoscale. 6-12 Metasurfaces enable the excitation of multiple resonant modes, which interact through near-□eld coupling and constructive or destructive interference, resulting in Fano resonances characterized by asymmetric line shapes and linewidths tunable through precise control of the coupling strength and resonance detuning. 13-16 Several designs involving EO metasurfaces and exploiting the Pockels effect have been demonstrated in recent years, including those based on thin-□lm layers (o□en called "etchless")17-31 and patterned layers of EO crystals. 32-43 Some of the designs involve both patterned and unpatterned EO layers underneath the patterned part, 34,35 as well

as other innovative approaches with patterning and structuring of an EO material with the aim of placing it in the region of the highest \Box eld of the mode. 44,45 The most common EO crystals used are lithium niobate, 9,10,17-26,31-38,42-46 barium titanate, 8,27,39-41,47 and

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Paper RSC Advances

bismuth ferrite.^{28–30} Other designs involve EO sol-gel synthesis, nanoparticles, and nanocrystals of barium titanate, 47-51 as well as EO polymers. 52-58 Typically, large electric \square elds are needed to induce refractive index changes large enough for practical applications. The thin-□lm designs provide an advantage in nanofabrication because they do not involve etching and patterning of the EO crystals, and the metasurface elements (gratings or nanoantennas) are placed on top of the EO layer. Such designs o□en bene□t from utilizing resonant waveguide mode excitation and controlling the spectral position of this resonance. 18,23,24 Pronounced nonlocal properties can be achieved by the interplay of incident light and widely spread modes propagating across surface structures (that is, the metasurface elements). In contrast, the fabrication of nanoantennas and gratings of EO material requires etching, which complicates the process and makes it less practical. However, on the positive side, this nanostructuring results in a tighter mode localization and stronger EO response. Because of the higher optical \square eld in proximity to the patterned part, the response to the change in refractive index results in a stronger shi□ of the spectral features. Patterned and unpatterned EO crystals have been shown to be particularly promising for wavefront shaping and beam steering.^{26,37}

Although metasurfaces and other nanophotonic designs help to enhance mode localization within or near the EO material, the reported spectral shi□s of the resonant features remain relatively small for realistic biasing because of the inherently weak EO response of the material. Practical limits to the driving Delds are imposed by considering the energy consumption and the breakdown strength of the materials and nanostructure. Other limitations are related to the transparency range of conventional materials. To address the upcoming challenges of future nanophotonic and optoelectronic technology, it is critical to develop novel materials with an enhanced EO response that can be chip-integrated. These materials are expected to provide novel, innovative technologies and enable nanophotonic devices with higher performance, reduced size and cost, and new functionalities. At the same time, the investigation of nanostructures is far from complete, and new behavior could emerge from exploring the vast parameter space of their geometry and inner structure. The present work proposes an approach to achieve efficient EO light manipulation with the current generation of EO materials.

Chalcophosphates are a family of materials with a general structure $M_2P_2S_6$, where M is a divalent metal, many of which are known to be ferroelectric and piezoelectric. They also typically have small bandgaps and low melting points. Within this family of materials, $Sn_2P_2S_6$ is one of the most widely studied compositions, $^{59-63}$ and it is known to exhibit EO properties, 61 photorefraction, 64,65 and enhanced second-harmonic generation 62,66 due to its non-centrosymmetric crystal structure.

In addition, $Sn_2P_2S_6$ has a Curie temperature (transition from ferroelectric to paraelectric phase) of only 64–66 °C. 61,67,68 The proximity of this transition to room temperature, coupled with its large EO coefficient, presents a promising avenue for inducing substantial changes in the refractive index of the material under driving conditions that can be implemented relatively easily. In fact, the EO coefficient is known to increase

signi□cantly when the temperature approaches the Curie temperature from below,^{61,69} but for most traditional EO materials, such as lithium niobate, the Curie temperature is too high to make this regime useable in practice.

Recent work⁷⁰ has reported on the outstanding properties of a related material, SnP₂S₆, whose EO coefficient is superior to well-established EO materials, such as lithium niobate. Thus, chalcophosphates⁷⁰⁻⁷⁴ offer promise in frequency conversion and as active infrared EO materials for applications that require signi□cant modulation of the refractive index in everyday settings and/or over small pathlength. The potential of these materials has not yet been explored, and this class of chalcophosphates has not yet been incorporated in functional metastructures.

In this work, we start to investigate this area by simulating numerically the optical properties of chalcophosphate-based metasurfaces with higher-order multipolar resonances excited in interconnected nanoantennas. We aim to develop the structure and enhance the EO response beyond what bulk and conventional materials offer. The large and temperature-controllable EO effect in the chalcophosphate metasurfaces can provide a means to induce signi cant variations in the refractive index. The corresponding tuning of the metasurface resonances is expected to be larger with chalcophosphates than with conventional EO materials, thus yielding increased efficiency or tailorability to the resulting devices.

Based on earlier studies of high-refractive-index nanostructures and the similarity of nanoantenna modes, we anticipate that an electric quadrupole mode couples to other even modes and can cause a resonant magnetic response of an antenna because of wave re□ections from its boundaries. We computationally show that the proposed metasurfaces exhibit a notable shi□ of multipolar resonances when the refractive index is changed as a result of the EO effect, using a realistic bias near the Curie temperature. This is despite the moderate refractive index of the chalcophosphate and the reduced nanoantenna mode localization in comparison to conventional high-refractive-index materials, such as silicon. The simulations also show that the magnetic octupolar resonance exhibits the most pronounced shi□ in spectral features (peaks and dips), a phenomenon that we ascribe to the strongest localization of higher-order multipolar modes. This increased mode con nement contributes signi cantly to the observed spectral changes. In contrast, lattice resonances, which are based on nonlocal properties of the array and collective effects, provide relatively weak shi□s of spectral features. We engineer metasurfaces with both in-plane and out-of-plane biasing by introducing bridges connecting the nanoantennas and thin conductive layers surrounding the EO material. The bridges and conductive layers have only a small effect on the multipolar modes, and the magnetic octupolar resonance remains the most bene □cial for shi □ing the spectral features.

2 Multipolar resonances of EO metasurfaces

In nanoantennas made of high-refractive-index materials, such as silicon and III–V compounds, strong resonances are enabled

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by a high relection from the nanoantenna boundaries and strong mode localization associated with them. However, the refractive indices of EO crystals, such as $Sn_2P_2S_6$ (n = 2.7-2.8(ref. 63)), lithium niobate (n = 2.2-2.3 (ref. 75)), barium titanate, strontium titanate, and others, are considered moderate in the near-infrared range. Nanoantennas with moderate refractive index support relatively weak resonances, making the □eld localization not as strong as in high-refractive-index nanoantennas. Furthermore, realistic metasurfaces need to be placed on low-refractive-index substrates, resulting in lower relection from the nanoantenna boundaries and even lower mode localization. These restrictions coming from the material response broaden the metasurface resonances, and nanoantennas need to be selected with larger dimensions to support the same variety of multipolar resonances (electric and magnetic dipole, quadrupole, etc.) as in the high-refractiveindex nanoantennas.

To start with, we consider a periodic array of cuboid nanoantennas made of EO materials with properties similar to $Sn_2P_2S_6$ (Fig. 1a–c). The nanoantennas are connected in the *y*-direction. The bridge width w = 80 nm is \Box xed throughout the work. Similar designs of interconnected nanoantennas have been explored in earlier works^{76–79} and have been shown to be bene \Box cial when an electric \Box eld needs to be applied to the entire nanoantenna array. EO properties of \Box nite-size lithium niobate arrays of \sim 20–25 mm in characteristic dimensions have also been characterized.³⁴

The dimensions of the nanoantennas a_x , a_y , and a_z are varied, keeping $a_x = a_y = a_z$. Several periods of the array, D_x and D_y , are considered. We analyze these nanoantennas with an

assumption of n = 2.7, and we consider an extended near-infrared and telecommunication range of 1300–1800 nm. We assume that the refractive index of the nanoantenna n is isotropic (a discussion of the effect of anisotropy is included later in Section 3).

To account for realistic aspects of the design, we consider nanoantennas placed on a substrate with a refractive index of n_s = 1.47, surrounded by the same material, and covered with a superstrate matching the refractive index of the substrate. The general schematic includes electrodes on both sides of the interconnected nanoantennas along the y-direction. A large number of nanoantennas are assumed between the electrodes in the simulations, but, for simplicity only a relatively small number of nanoantennas are shown in Fig. 1a. This schematic corresponds to the case where the biasing (the static electric \Box eld) is applied in the *y*-direction. The light is incident normal to the metasurface (z-axis propagation direction) with x-polarization. It should be noted that the schematic does not show the surrounding medium, as, apart from the electrodes, the antennas are fully embedded by it and thus would not be visible.

Unless stated otherwise, the optical properties of the EO nanoantennas are computed using the commercial so \square ware CST Studio Suite. The calculated transmittance for a dense array as a function of the antenna dimension is shown in Fig. 1d. For $D_x = D_y = 750$ nm and a varied cuboid side $a_x = a_y = a_z$, the metasurface supports four resonances manifested as dips in the transmittance spectra, with near-zero transmittance. These spectral features shi \square to the red upon an increase in the cuboid side. In the subsequent analysis, we focus on the wavelength

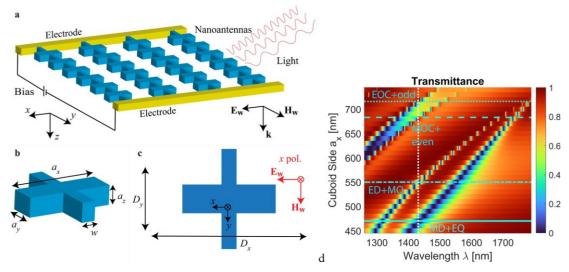


Fig. 1 Schematic of the structure and its transmittance. (a–c) Interconnected nanoantennas made of an EO crystal (light blue color) and arranged in an array, forming a metasurface. (a) Schematic 3D view of the metasurface and the electrodes connecting the nanoantennas on each end (yellow color). The surrounding medium in all directions (below, above, and around) is silica. (b) 3D view of one nanoantenna with the bridge. (c) Top view of the unit cell and orientation of the electric and magnetic fields of the light wave relative to the nanoantenna. (d) Transmittance of the metasurface for $D_x = D_y = 750$ nm and varied cuboid side $a_x = a_y = a_z$. The white dashed vertical line corresponds to a wavelength of approximately 1430 nm, which is chosen for subsequent analysis. The solid, dot-dashed, dashed, and dotted horizontal cyan lines correspond to the side values of 470, 550, 683, and 716 nm, respectively, which are considered in more detail later. This set of parameters results in four resonances manifested as dips in the transmission spectrum with near-zero transmittance. The labels and assignment of the various resonance types are described and justified later in the text.

 $\sim\!1430$ nm (vertical dashed line in the \Box gure) as we observe all four resonances in this range. The nanoantenna dimensions and array period can be scaled to obtain resonances in other ranges of the infrared spectrum.

We present the transmittance spectra for $D_x = D_y = 750 \text{ nm}$ and $a_x = a_y = a_z = 650$ nm in Fig. 2a for two values of the refractive index. One can see that the spectral features - peaks and dips - are very narrow, and upon a change in the refractive index of the EO crystal by Dn = 0.02, which is obtainable, for example, by application of an appropriate electric □eld, the features shi□ drastically, as this spectral shi□ is comparable to the width of the transmittance feature in most cases. Such a drastic shi□ gives an opportunity to effectively control the signal and tune the metasurface response. For comparison, for a uniform thin □lm continuous □at layer - with the same thickness of 650 nm and refractive index as the cuboid nanoantenna, the transmission spectrum does not show any sharp features, only exhibiting broad Fabry-Perot oscillations (see Fig. S1 of the ESI†). Additionally, the change in transmittance for the uniform \Box lm at any given wavelength when the refractive index is changed is much smaller than for the nanoantenna array.

With the period dimensions $D_x = D_y = 750$ nm and the surrounding medium refractive index $n_{\rm S} = 1.47$, the Rayleigh anomaly (RA) at the longest wavelength is $l_{\rm RA} = n_{\rm S}D_x = 1102.5$ nm. This is much shorter than the wavelength at which the nanoantenna dipole resonances are excited, and thus the array can be considered dense. In such a dense array, the spectral positions of the nanoantenna resonances are close to those of the

isolated nanoantenna. In contrast, in a nanoantenna array where the RA is spectrally close to the nanoantenna resonances, diffractive and collective phenomena play a crucial role, and we consider one of such cases later in this section.

A multipolar decomposition is performed for nanoantennas with the same parameters as in Fig. 2a, and the results are shown in Fig. 2b. This is carried out considering the scattered electromagnetic waves of local polarization sources and analyzing them using multipoles as the fundamental components (see ESI† for details on multipolar expressions). The procedure involves conducting full-wave numerical simulations, extracting the electric □eld distribution across the numerical domain at the speci c spectral points, and integrating these □elds to derive the corresponding multipolar contributions.80 It accounts for all characteristics included in the numerical simulations (nanoantenna shape, metasurface surrounding, interconnection of nanoantennas by the bridge, etc.). Multipolar decomposition is a highly accurate method for determining multipolar components, offering a more precise and quantitative analysis compared to relying on □eld distribution alone, which is inherently qualitative.

The effective polarizabilities of each multipole are normalized based on the coefficients used in the calculations of re□ection and transmission,⁸¹ re□ecting the respective contributions to the overall array response. Multipoles can be even or odd, and they couple strongly within their group, resulting in the resonances of other multipoles within the group. The □rst mode in the metasurface transmittance spectrum (following the

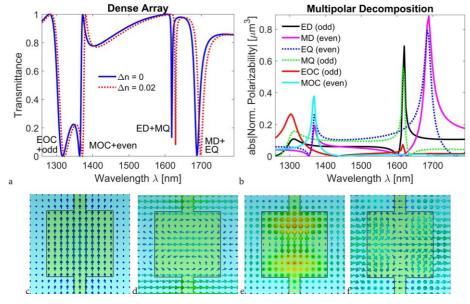


Fig. 2 (a) Transmittance of the dense nanoantenna array with $D_x = D_y = 750$ nm and $a_x = a_y = a_z = 650$ nm. The solid line corresponds to the unbiased crystal (n = 2.7, $D_n = 0$). The dashed line shows the results for the biased crystal corresponding to an isotropic change in refractive index $D_n = 0.02$. Four multipolar modes result in the dips in the transmittance, and the dips are shifted upon biasing the crystal. (b) Multipolar decomposition for the case of an unbiased crystal: absolute value of the normalized effective polarizabilities. Here, "E" and "M" stand for electric and magnetic, and "D", "Q", and "OC" stand for dipole, quadrupole, and octupole, respectively. The electric dipole term includes a toroidal component. (c–f) Field distributions corresponding to the four resonances with different modes: (c) MD + EQ, (d) ED + MQ, (e) MOC + even, and (f) EOC + odd for $D_x = D_y = 750$ nm and $a_x = a_y = a_z = 470$ nm. The magnetic field H is shown in panels (c) and (e), which correspond to predominantly magnetic modes. The electric field H is shown in panels (d) and (f), which correspond to predominantly electric modes. The arrow lengths correspond to the relative field normalized to the magnitude of the incident field.

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convention, we count starting with the longest wavelength) originates from the resonances of a magnetic dipole (MD) and an electric quadrupole (EQ), both of which are even multipoles. The second mode originates from the resonances of an electric dipole (ED) and a magnetic quadrupole (MQ), both of which are odd multipoles. The next higher-order modes are magnetic octupole (MOC) with other even multipoles and electric octupole (EOC) with other odd multiples. Throughout this work, we assign labels to the spectral features according to the nature of the resonances we identify in this multipolar decomposition (this is the meaning of the labels used earlier in Fig. 1d).

In addition to performing the multipolar decomposition, we present the electric and magnetic □eld pro□les of the resonances, directly correlating them with speci□c multipolar modes at the wavelengths corresponding to each resonance. These distributions show the mode structure, helping to understand their contributions to scattering. In Fig. 2c–f, we show the □eld distributions corresponding to the MD + EQ, ED + MQ, MOC + even, and EOC + odd modes, respectively. In panels (c) and (d), one can clearly see dipolar Deld distributions. However, higherorder modes in panels (e) and (f) are less clear, as they include different even and odd components dominated by octupoles.

Lattice modes can be important in metasurfaces with varying periodicities, as they can signi□cantly affect the tunable response of the structure. In our study, while the primary focus is on the optical properties induced by multipolar resonances, lattice modes can also play a critical role, especially in contributing to collective effects and modifying the resonance conditions. To address this and to provide a more comprehensive understanding of their impact on the metasurface EO tuning performance, we conduct an analysis of lattice modes and their change with refractive index.

Nonlocal, collective effects have been known to result in narrow resonances. These spectral features are excited in proximity to the RA, as the latter corresponds to the emergence of new diffraction orders. Thus, lattice resonances can be controlled by the array periods D_x and D_y . They are also affected by the dimensions of the nanoantennas. We utilize this property to design an array of interconnected nanoantennas with lattice resonances. In Fig. 3a, we show these resonances for the case of D_x = 940 nm and D_y = 750 nm and the change in their position for different dimensions of the nanoantenna. In this case, the wavelength of RA at the longest wavelength is $l_{RA} = n_s D_x =$ 1381.8 nm. These lattice resonances are based on even multipoles (MD, EQ, and MOC) and thus referred to as 'LR1 (even)'. In Fig. 3a, we see that the resonance is narrower for nanoantennas with the cuboid side of 300 nm than for the side of 380 nm. For the smaller nanoantennas, the resonance is excited closer to the RA and is narrower in bandwidth, which is consistent with the properties of lattice resonances. 4,82 Fig. 3a also shows that the lattice resonances of smaller nanoantennas experience smaller spectral shi \square s with a change in refractive index (Dn = 0.02 in the □gure) than the lattice resonances for larger nanoantennas.

Having identi□ed multipolar resonances in the dense array and lattice resonances in the same spectral range, we next analyze how far the resonance can be shi ☐ed upon a change in the refractive index of the EO crystal (Fig. 3b). We choose again

Dn = 0.02, and we calculate the shi \square of all the resonances we identi ded earlier. We adjust the dimensions of the nanoantennas so that the resonances are excited approximately at the same wavelength ~1430 nm. Mode localization is calculated by introducing a very small absorption of the nanoantenna material and calculating the absorption in the nanoantennas. The resonance width is calculated as the full width at half maximum (FWHM), that is, the width of a spectral feature at half of its maximum amplitude.

One can observe that higher-order multipolar resonances in the dense array, such as EOC and MOC, exhibit resonance shi□s larger than lower-order multipolar resonances, such as dipoles and quadrupoles. One can also see that the resonance width of the higher-order multiples is narrower and that the mode localization is higher (dark red and greenish colors on the colorbar as opposed to blue and light blue). These observations are consistent with the properties of higher-order multipolar modes in single nanoantennas.

It can also be seen that, compared to the lattice resonances in the sparse arrays, the multipolar resonances of the dense array exhibit larger shi□s in general, even for comparable resonance widths. Mode 'LR1 (even)' exhibits slightly better performance than 'LR2 (odd)', resulting in a marginally larger shi□ of the resonance and higher mode localization. The mode localization of the □eld in branch 'LR1 (even)' can be as high as one in the EOC resonance of the dense array (the same greenish color in the colorbar). For nanoantenna dimensions \$ 300 nm, LR1 and LR2 have widths comparable to or broader than multipolar resonances in the dense array. Smaller nanoantennas result in resonances that are very narrow.

Collective resonances occur because of the coherent scattering of the multipoles in the periodic lattice close to the diffractive regime. Lattice resonances have been extensively analyzed with respect to the change in the refractive index of the surrounding medium, especially in regard to sensing applications. 4,83-85 The lattice resonances have been shown to be very responsive to a change in the refractive index of the surrounding medium. However, the resonance response to the change in the refractive index of the nanoantenna has not received the same attention. Our analysis shows that the lattice resonances are relatively robust to changes in the refractive index of the nanoantenna, yielding only a very small shi \square in resonance position when the refractive index of the nanoantenna is changed. Because of this, these lattice resonances do not provide a particularly useful handle if a tunable structure is sought. The main reason for these properties is the delocalized nature of the lattice mode. In the next section, we focus on the analysis of the four modes that correspond to the dense array with $D_x = D_y = 750$ nm, as these modes demonstrated the largest shi□s with respect to the change in refractive index.

Chalcophosphate metasurfaces with in-plane bias

As mentioned in the Introduction, the current selection of commercial infrared EO materials is rather limited, especially

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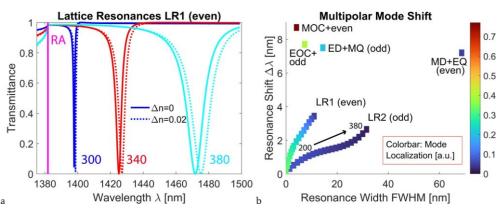


Fig. 3 (a) Transmittance spectra of the nanoantenna arrays supporting lattice resonances. Here, $D_x = 940$ nm and $D_y = 750$ nm. The wavelength of the Rayleigh anomaly (RA) $I_{RA} = n_s D_x$ is denoted as a vertical magenta line. Three sets of nanoantennas are considered: 300, 340, and 380 nm in dimensions $a_x = a_y = a_z$. The solid and dashed lines show the spectral features for the unbiased ($D_x = 0$) and biased ($D_x = 0.02$) crystal. (b) Summary of resonance shifts for different multipoles: four modes of the dense array and two lattice resonances are considered. The shift is determined for $D_x = 0.02$. MD + EQ mode is analyzed for $a_x = a_y = a_z = 470$ nm, ED + MQ for 550 nm, MOC + odd for 683 nm, and EOC + even for 716 nm. Different dimensions of the nanoantennas are considered to shift their resonances to the same spectral position of \sim 1430 nm. $D_x = D_y = 750$ nm for all calculations of the dense array. Branches 'LR1' and 'LR2' corresponding to lattice resonances of even and odd multipoles are calculated by varying the nanoantenna dimensions. Branch 'LR1 (even)' is for $D_x = 940$ nm and $D_y = 750$ nm, and branch 'LR2 (odd)' is for $D_x = 750$ nm and $D_y = 940$ nm. For both branches 'LR1 (even)' and 'LR2 (odd)', the nanoantenna dimensions $a_x = a_y = a_z$ range from 200 to 380 nm. The resonances for the sparse arrays form branches rather than one point, as in the case of a dense array.

for operation in the mid- and far-infrared range (2.5–20 mm), and the magnitude of the EO coefficients for most is such that very large □elds or long pathlengths are needed to achieve refractive index changes of practical use. Other material limitations are related to the tendency for layered growth, low laser-induced damage thresholds, absorption losses, and toxicity.

One promising material in the chalcophosphate family is tin thiohypodiphosphate, Sn₂P₂S₆, which is ferroelectric at room temperature but has a low Curie temperature (64.7 °C),61 has substantial EO coefficients,61 and has an extensive transparency range (from l = 0.53 mm to l = 8 mm).⁶² The EO coefficients for this material are already relatively large at room temperature (the largest reported component, r_{111} , is +174 \pm 10 pm V⁻¹ at 633 nm and room temperature⁶¹) and larger than lithium niobate. Since the EO coefficients increase with increasing temperature up to the Curie point, signi \Box cantly larger r_{ijk} values than at room temperature could be achieved by judicious control of the temperature, at least for some of the tensor components, thus offering the potential for considerable changes in the refractive index under manageable conditions. This is illustrated in Fig. 4a, where the blue line in the main graph shows the value of r_{111} as a function of temperature, according to the parameters reported in ref. 61. r_{111} values as high as 3000 pm V^{-1} are possible in the vicinity of $T_{\rm C}$.

The inset shows the variation in the absolute value of the refractive index, $jDnj = (1/2)n^3rE$, achievable as a function of r for three values of the applied electric \Box eld. It can be seen that for a bias of 6.5 kV mm⁻¹, a change in the refractive index as high as Dn = 0.2 could be realized. To our knowledge, the breakdown \Box eld for $Sn_2P_2S_6$ has not been reported in the literature. For reference, the breakdown \Box eld for lithium niobate has been reported to be E = 70–80 kV mm⁻¹,86 and we can assume that 6.5 kV mm⁻¹ is safely below the breakdown for the

chalcophosphate of interest. The absolute refractive index changes achievable as a function of temperature for this applied voltage are shown on the right ordinate axis of the main graph in the same \Box gure. An even higher jDnj can be achieved with larger biases (see the cyan line in the inset of Fig. 4a). Complementing the results presented here, Fig. S4 of the ESI† shows the induced change in the refractive index Dn that can be achieved for different biases E and temperatures close to T_C (T = 336, 337, and 337.5 K). One can see that a substantial change in the refractive index Dn = 0.5 can be achieved for realistic bias values up to 12 kV mm $^{-1}$, provided the crystal temperature can be stabilized with sufficiently small \Box uctuations just below the Curie temperature. Thus, Sn₂P₂S₆ is a promising candidate for applications requiring signi \Box cant changes in the refractive index.

It should be noted that $Sn_2P_2S_6$ is anisotropic (with $n_i - n_j \sim$ 0.1 or slightly higher, as shown in Fig. S2a†) and that more than one component of the refractive index matrix could be changed (and to a different extent) by various combinations of electric □eld and polarization directions. Furthermore, off-diagonal components of the refractive index can be non-zero or become non-zero when the □eld is applied, resulting in changes in the polarization eigenmodes. Here, we consider this to be a minor effect and neglect it, assuming that only diagonal components of the refractive index matrix are changed by the applied \square eld and that all diagonal elements are changed to the same extent. This is justi □ed by the following observations: (1) it was tested that the dispersion of the refractive index for Sn₂P₂S₆ (Fig. S2a†) affects the spectral pro□les of the array only very weakly (Fig. S2b†). (2) If a weak refractive index anisotropy was introduced in the absence of bias, it was found not to cause excitation of any additional modes in the nanoantennas and only shi□ their position with respect to the isotropic material

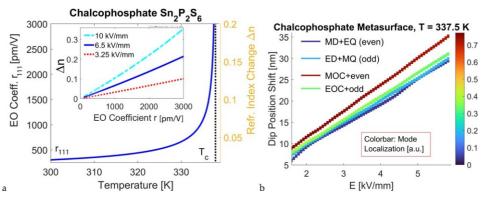


Fig. 4 (a) EO coefficient r_{111} for $\mathrm{Sn_2P_2S_6}$ as a function of temperature (left ordinate axis). $T_\mathrm{C} = 64.7~\mathrm{C}$ is shown by the vertical black dotted line. Data are taken from ref. 61. The corresponding induced changes in the refractive index for $E = 6.5~\mathrm{kV}~\mathrm{mm}^{-1}$ are shown on the right ordinate axis. Inset: The absolute change in refractive index as a function of the value of r for three different magnitudes of the electric field E. (b) Shift of the dip position for four modes of the dense arrays with respect to the bias field E. Calculations are performed for r_{221} (room temperature value, 92 pm V⁻¹, and temperature dependence from ref. 61), $T = 337.5~\mathrm{K}$ (64.35 °C), and $D_x = D_y = 750~\mathrm{nm}$. Similarly to Fig. 3, MD + EQ mode is analyzed for $a_x = a_y = a_z = 470~\mathrm{nm}$, ED + MQ for 550 nm, MOC + odd for 683 nm, and EOC + even for 716 nm. The colorbar indicates the mode localization defined in the same way as in Fig. 3.

(Fig. S3†). As a consequence, one could expect that an anisotropic change of refractive index Dn would not signi□cantly affect the spectral features in comparison to the isotropic case. Even nanoantennas made of the highly anisotropic van der Waals material MoS₂, with drastically different (but positive) inplane and out-of-plane permittivity components, support resonance excitations similar to those in silicon nanoantennas (see ref. 87). Thus, the general conclusions about the type of modes and their behavior reached in the approximation of an isotropic refractive index of the EO nanoantennas should also hold for a more realistic – anisotropic – material. In this way, our calculations are the estimates of the largest possible resonance shi□. A more complete accounting of anisotropy effects on nanoantenna resonances and EO-induced shi□s will be considered in the follow-up work.

The considerations above are based on r_{111} , which is the largest component of the EO tensor for Sn₂P₂S₆. However, it requires the applied bias □eld to be parallel to the polarization direction, that is, the applied □eld and polarization are along the y-axis, which is not the case here. Instead, it is possible to orient the Sn₂P₂S₆ crystal before patterning it in the nanoantennas such that the active component of the EO tensor is r_{221} , as described below. Let us use capital letters to refer to the crystal frame of reference to avoid confusion with the laboratory frame x, y, z in Fig. 1a, and the same axes convention for a single crystal of Sn₂P₂S₆ as in ref. 61. To realize a structure like the one shown in Fig. 1a, we could envision nanoantennas made from Sn₂P₂S₆ oriented as follows: the Z axis of the crystal aligns with the propagation direction z of light through the structure, X is parallel to y (and thus E), and Y is parallel to x, the polarization direction considered in this work. No change in the orientation of the index ellipsoid is induced by an electric □eld applied along y = X (it should be noted, however, that the index ellipsoid is rotated relative to the X, Y, Z-frame for the zero \Box eld).

We then perform numerical simulations of the metasurface when the refractive index is tuned by the \Box eld E at a temperature close to $T_{\mathbb{C}}$, and we track the shi \Box of the dip position for four

modes of the dense array (Fig. 4b). For these calculations, a value of $r_{221} = 92$ pm V⁻¹ is used (ref. 61, neglecting the small wavelength dispersion from the visible to the near-infrared range).

One can see that for all modes, the dip position $\sinh\Box$ increases with a higher electric \Box eld. The mode 'MOC + even' experiences the fastest $\sinh\Box$ even though the mode localization is slightly reduced for the larger bias value. The other three modes demonstrate a comparable $\sinh\Box$, with 'EOC + odd' having a slightly larger $\sinh\Box$ than the other modes. Depending on the mode, a $\sinh\Box$ of 28–35 nm can be achieved for a bias of E = 6 kV mm $^{-1}$. The dip position can also be changed with temperature while maintaining a \Box xed electric \Box eld (as shown in Fig. S5 of the ESI \dagger).

In the calculations, we assume a positive change in the refractive index Dn (that is, Dn > 0). In practice, the sign of the index change can be controlled by the direction of the applied bias, allowing to obtain positive and negative Dn. An EO device operating based on the variation from -Dn to +Dn has improved performance. In our analysis, we observe a near-linear shi \square in the spectral positions of the features, and we do not expect any particularly different effects for Dn < 0. These results demonstrate the great potential of the chalcophosphate metasurface for EO applications since a signi \square cant shi \square of the spectral features can be obtained with reasonable bias.

4 Chalcophosphate metasurfaces with out-of-plane bias

The metasurface design considered above assumes interconnected nanoantennas and electrodes on both sides of the nanoantenna array. This design implies that an electric □eld (bias) is applied along the chain of interconnected nanoantennas (in the plane of the nanostructures), which have an approximate length of tens of micrometers. Achieving a bias of up to several kV mm⁻¹ would require relatively high voltages, which, in turn, could lead to higher chances of leakage and breakdown, especially around the defects of the metasurface.

To mitigate this challenge, an alternative approach is to apply the bias perpendicular to the metasurface (Fig. 5a). We refer to this con guration as out-of-plane biasing. Once again, the orientation of the Sn₂P₂S₆ crystal in the nanoantennas determines which component of the EO tensor is active in the target con □guration. The out-of-plane biasing con □guration can be realized by orienting the Sn₂P₂S₆ in the nanoantennas in one of two ways (using the same crystal frame of reference as in Section 3): (i) the crystal's X-axis is parallel to z of the device (and thus to E), Y is parallel to y, and Z is parallel to x (polarization direction of light). This selection exploits the r_{331} component of the EO coefficient, which has been reported to be 140 pm V^{-1} at 633 nm and larger than r_{221} .61 (ii) An alternative selection is again with X parallel to z, but with the reverse role of the other two crystal axes (i.e., Y parallel to x, and Z parallel to y) and exploiting the r_{221} component. The latter selection is used for the simulation.

From a practical point of view, the out-of-plane bias con \(\]g-uration requires a layer of conductive material on the top and bottom of the nanoantennas (yellow-colored layers in Fig. 5a). Examples of materials that can be used as electrodes are doped

silicon and indium tin oxide (ITO). The layers of silicon or ITO could be etched in the same fabrication step as the etching of the chalcophosphate crystal. The design with an active layer sandwiched between the electrodes is very common in general, as it is proven to be useful for enhancing \Box eld localization in the core part of a multilayer structure as well as biasing an active material in the out-of-plane direction. 14,37,77,88

We perform simulations of the periodic array of interconnected nanoantennas with top and bottom conductive layers and surrounded by silica, and we analyze the shi of the spectral features as a function of the electric oeld (Fig. 5b) and the effect of electrode thickness on the transmittance spectra of unbiased nanoantenna arrays (Fig. 5c and d). In panels b-d, the array is dense, and $D_x = D_y = 750$ nm. When we consider electrode layers made of silicon, we use the permittivity data for amorphous silicon, taking into account dispersion but assuming negligible losses. The permittivity data are taken from the refractive index. info database referring to ref. 89. Doping levels up to 10^{19} cm⁻³ do not cause high material losses and should provide sufficiently high conductivity and small resistance for use in the nanoantenna device. From the simulation

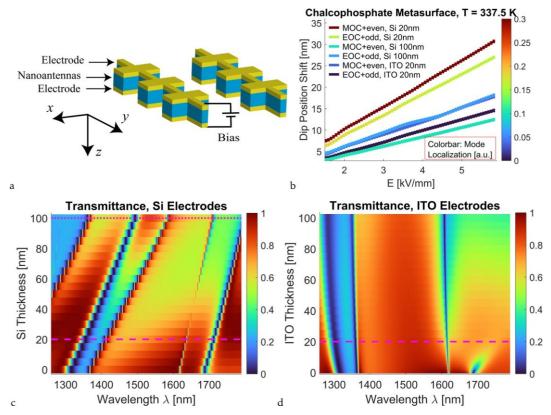


Fig. 5 Metasurface for out-of-plane biasing, with thin electrode layers of silicon or ITO. (a) Schematic of the layout with conductive layers (yellow) above and below the chalcophosphate nanoantennas (blue). The upper and lower electrodes have the same thickness. (b) Shift of the dip position for MOC + even and EOC + odd modes in the chalcophosphate metasurface with electrodes as a function of the electric field. Calculations are conducted for r_{221} and for T = 337.5 K (parameters from ref. 61). The colorbar indicates the mode localization defined in the same way as in Fig. 3. Results are shown for silicon electrodes with thicknesses of 20 and 100 nm and ITO electrodes of 20 nm. Other dimensions of the metasurface are the same as those used above. (c) Transmittance of the metasurface with silicon layers of varying thickness for the unbiased crystal (Dn = 0). The 20 nm and 100 nm cases are shown with dashed and dotted horizontal lines, respectively. Chalcophosphate cuboids have $a_x = a_y = a_z = 650$ nm. The resonances experience redshift with increasing thickness of the silicon layer, but all four resonances remain clearly visible even for thicker silicon layers. (d) Transmittance of the metasurface with ITO layers of varying thickness and an unbiased crystal (Dn = 0). Chalcophosphate cuboids have $a_x = a_y = a_z = 650$ nm. The 20 nm case is shown with the dashed horizontal line.

results, one can see that changing the thickness of the silicon layer does not result in a signi □cant alteration of the nanoantenna modes (Fig. 5c). The nanoantennas with electrodes exhibit the same four modes as those observed earlier for nanoantennas without the electrode layers. Thicker layers of silicon result in a redshi□ of the modes. An additional broad dip originating from the two resonances emerges for thicker silicon (>60 nm) and also experiences a redshi□ with increasing Si thickness. When a bias is applied, 20 nm silicon layers result in a dip position shi□ only slightly smaller than for nanoantennas with in-plane bias (compare Fig. 5b to 4b). 100 nm silicon layers result in a □eld-induced shi□ smaller by about a factor of two than the one for 20 nm-thick silicon layers. One can observe that the trend changes with the \Box Im thickness, and the shi \Box of the MOC mode is not as drastic as that of the EOC one because modes corresponding to the different multipoles have a different response to the adjacent material.

The alternative conductive electrode material we consider is ITO (Fig. 5d). We take the ITO permittivity parameters from ref. 90 for the case of ITO annealed for 10 hours. This procedure has been shown to result in ITO with signi □cantly reduced absorption losses compared to as-deposited ITO reported in the same source or ITO data reported in other sources, e.g., in ref. 91. It is found that the MD + EQ mode is not present for the metasurfaces with ITO layers. The other nanoantenna resonances are present and experience a slight blueshi□ with increasing ITO thickness. The signi cant decrease in transmittance and the disappearance of the spectral feature as the ITO thickness increases are caused by absorption losses in ITO. ITO layers of 20-40 nm have resistance ~100 U,92 so we select 20 nm for the analysis of the change in spectral characteristic as a function of the applied electric \Box eld (Fig. 5b). Simulation results for ITO show that the mode shi□s are very similar to those for 100 nm silicon and around half of the shi□ possible for the nanoantennas without electrodes or with 20 nm-thick silicon electrodes.

5 Discussion

It is interesting to compare our design with other theoretical proposals of EO metasurfaces. For lithium niobate with Dn \sim 0.01 and bias voltage in both directions (effectively doubling the effect), the shi□ in the spectral feature (dip in transmittance) has been reported to be up to 8 nm. 18 This is comparable to the values we obtain for higher-order multipolar resonances, presented in Fig. 2a and 3 for a slightly longer wavelength range. However, such a shi□ for the lithium niobate case requires a bias close to the electrical breakdown of the material. This does not leave room for further enhancement of the effect and could increase the chance of device failure. In contrast, Sn₂P₂S₆ and other chalcophosphates allow for a substantial increase in Dn, and a shi \square of the spectral feature as large as 35 nm can be observed at substantially lower applied voltages, as shown in Fig. 4. Experimental measurements on the lithium niobate metasurface have demonstrated a 3 nm spectral shi□ of the re□ection dip upon bias variation of ±25 V and have been in good agreement with numerical predictions for the same

metasurface design.¹⁷ Theoretical analysis of silicon-on-lithium niobate metasurfaces for EO wavefront shaping and high quality factor has demonstrated a 0.1 nm shi \square of the re \square ectance dip with a ± 10 V bias.³⁷ Thus, chalcophosphates are promising for EO metasurfaces because of their signi \square cant Pockels effect at room temperature and its enhancement approaching $T_{\rm C}$, enabling efficient electric- \square eld-induced modulation of optical properties, and have the potential to provide modulation much larger than that of metasurfaces with lithium niobate.

Nanofabrication of metasurfaces made from crystalline materials, such as lithium niobate, silicon, or III-V compound, typically begins with crystal growth or bonding of a thin crystal layer onto a substrate (for example, silicon dioxide). The crystal layer thickness is then carefully reduced to the desired amount through processes such as polishing or chemical etching. Following this, an electron-beam resist is spin-coated onto the crystal surface, exposed with an electron beam lithographic write, and subsequently developed to create the desired pattern. A hard mask, o□en composed of a metal like chromium, is then deposited over the patterned resist, typically with an electronbeam evaporator in the case of a metal mask. The resist is lifted off, leaving the hard mask to protect speci □c areas during the subsequent etching process, which sculpts the crystalline material into the desired metasurface structure. Finally, a separate step is undertaken to fabricate electrical contacts, if required, for the metasurface or EO device based on it.

For the out-of-plane biasing con guration, the electrodes can be made of two-dimensional materials, such as graphene or transition metal dichalcogenides. Because of the ultra-thin layers, these materials should provide high conductivity and not signi cantly affect the metasurface optical response. However, from a fabrication point of view, they are still challenging to realize consistently and require difficult nanofabrication steps. Other possible designs include a bulk layer of chalcophosphate crystal with a pattern of holes, which, could support photonic-crystal-type modes.

6 Conclusions

We reported on theoretical results on high-performance EO chalcophosphate metasurfaces with interconnected nanoantennas supporting higher-order multipolar resonances. We computationally showed that this type of nanostructure is promising for realizing efficient subwavelength scatterers with tunable characteristics. We observed that a nanoantenna made out of $\mathrm{Sn_2P_2S_6}$ possesses several multipolar resonances enabled by the support of internal modes and their redection from the antenna boundaries. By exploring different antenna dimensions and designs, a full range of multipolar resonances (electric and magnetic dipoles, quadrupoles, octupoles, and higher-order multipoles) can be achieved.

Localized nanoantenna resonances in the dense array are shown to be more efficient than collective lattice resonances supported by the same nanoantennas in the same spectral range, even though the collective resonances are narrower. Tight mode localization in the nanoantennas and low Curie temperature of the chalcophosphate materials allow for Paper

a signi □cant shi □ of resonant spectral features (tens of nm's) with realistic bias due to the enhancement of the EO coefficient when approaching $T_{\rm C}$. Bridge interconnects and thin electrodes surrounding the nanoantennas facilitate biasing and have been shown to not diminish the EO characteristics of the metasurface. EO chalcophosphate metasurfaces can potentially revolutionize nanophotonic device concepts for various applications, such as modulators, sensors, and beam steerers, among others, operable in the infrared region.

Abbreviations

ED

EO Electro-optic **EOC** Electric octupole EQ Electric quadrupole **FWHM** Full width at half maximum ITO Indium tin oxide LR Lattice resonance MD Magnetic dipole MOC Magnetic octupole MQ Magnetic quadrupole RA Rayleigh anomaly

Electric dipole

Data availability

This study was carried out using commercial so □ware CST Studio Suite and COMSOL Multiphysics. CST Studio Suite can be contacted at the Simulia website https://www.3ds.com. The version of the code employed for this study is 2024. COMSOL Multiphysics can be contacted at https://www.comsol.com. The version of the code employed for this study is 5.6. The data supporting this article have also been included as part of the ESI.†

Conflicts of interest

The authors declare no con □icts of interest.

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